

Notice of References Cited	Application/Control No. 10/603,375	Applicant(s)/Patent Under Reexamination JUNG, JONG GOO	
	Examiner Heather A. Doty	Art Unit 2813	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-6,443,811	09-2002	Nojo et al.	451/41
	B	US-5,965,463	10-1999	Cui et al.	438/723
	C	US-6,471,735	10-2002	Misra et al.	51/308
	D	US-6,784,062	08-2004	Cho et al.	438/302
	E	US-2002/0170237	11-2002	Vogt et al.	51/308
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	J	US-			
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	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

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NON-PATENT DOCUMENTS

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	U	Hackh's Chemical Dictionary, ed. Julius Grant, MacGraw-Hill, Inc. 1969 (pg. 146).
	V	S. Wolf et al., Silicon Processing for the VLSI Era, v. 1, Lattice Press, 1986 (pp. 136-137, 143, 193-194).
	W	S. Wolf, Silicon Processing for the VLSI Era, v. 2, Lattice Press, 1990 (pp. 196-198, 212).
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.